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AF/2822
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AFTER FINAL

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Jung-hyun LEE, *et al.*

Art Unit: 2822

Serial No. 10/617,767

Examiner: J.B. Vockrodt

Filed: July 14, 2003

Confirmation No. 4046

For: Deposition Method of a Dielectric Layer

Attorney Docket No.: 249/349

AMENDMENT UNDER 37 C.F.R. §1.116

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Commissioner for Patents
United States Patent and Trademark Office
P.O. Box 1450
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Sir:

INTRODUCTORY COMMENTS

In response to the Office Action Made Final mailed September 2, 2004, the following amendments and remarks are respectfully submitted in connection with the above-identified application:

Amendments to the Claims are reflected in a listing of claims, which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.